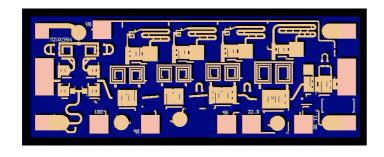


30 GHz 5-Bit Phase Shifter



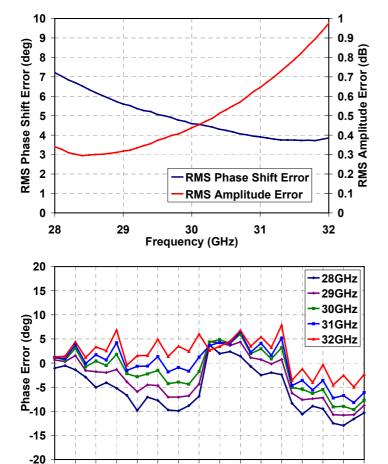


Key Features and Performance

- Positive Control Voltage
- Single-Ended Logic
- CMOS Compatible
- Frequency Range: 28 32 GHz
- 0.25µm pHEMT 3MI Technology
- Chip dimensions:

1.88 x 0.75 x 0.1 mm (0.074 x 0.030 x 0.004 inches)

Preliminary Measured Performance



11 13

State

Note: Devices designated as EPU are typically early in their characterization process prior to finalizing all electrical and process specifications. Specifications are subject to change without notice.

15 17 19 21 23 25 27 29 31



TGP2100-EPU

TABLE I MAXIMUM RATINGS

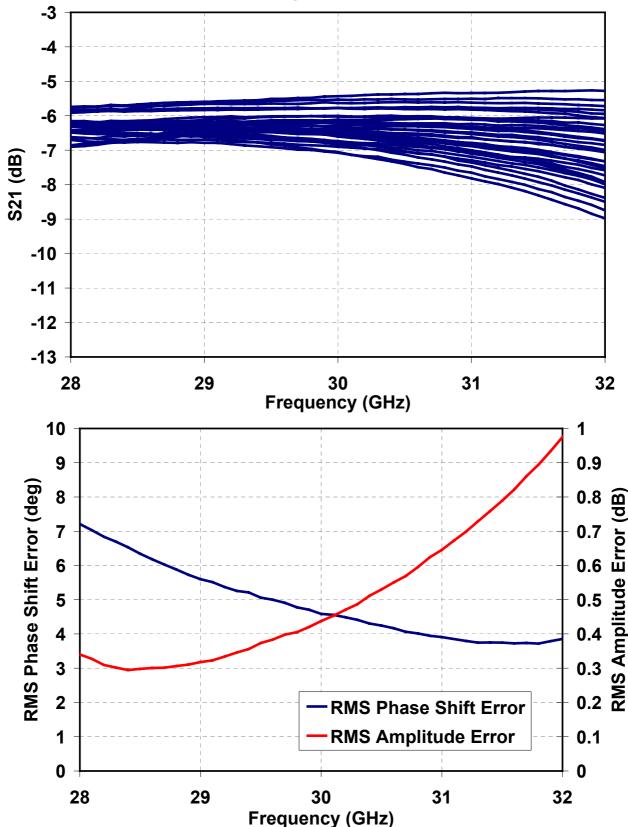
Symbol	Parameter	Value	Notes
V _C	Control Voltage Range	0 - +8 V	<u>1</u> / <u>2</u> /
I _D	Control Supply Current	1 mA	<u>1</u> / <u>2</u> /
P _{IN}	Input Continuous Wave Power	20 dBm	<u>1</u> / <u>2</u> /
P_D	Power Dissipation	0.1 W	<u>1</u> / <u>2</u> /
T _{CH}	Operating Channel Temperature	150 ⁰ C	<u>3</u> /
T _M	Mounting Temperature (30 Seconds)	320 °C	
T _{STG}	Storage Temperature	-65 to 150 ⁰ C	

- 1/ These ratings represent the maximum operable values for this device
- **2**/ Combinations of supply voltage, supply current, input power, and output power shall not exceed P_D at a package base temperature of 70°C
- <u>3/</u> Junction operating temperature will directly affect the device median time to failure (MTTF). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.



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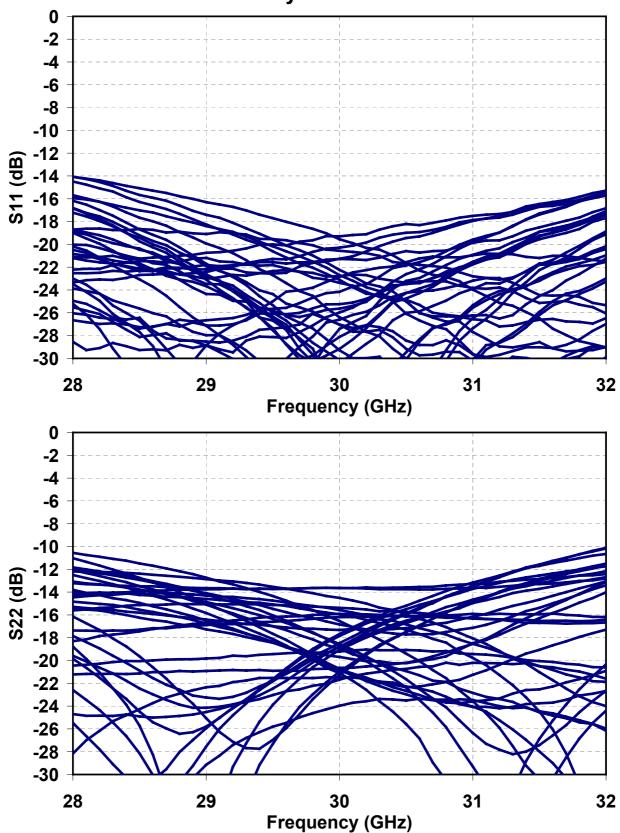
Preliminary Measured Data





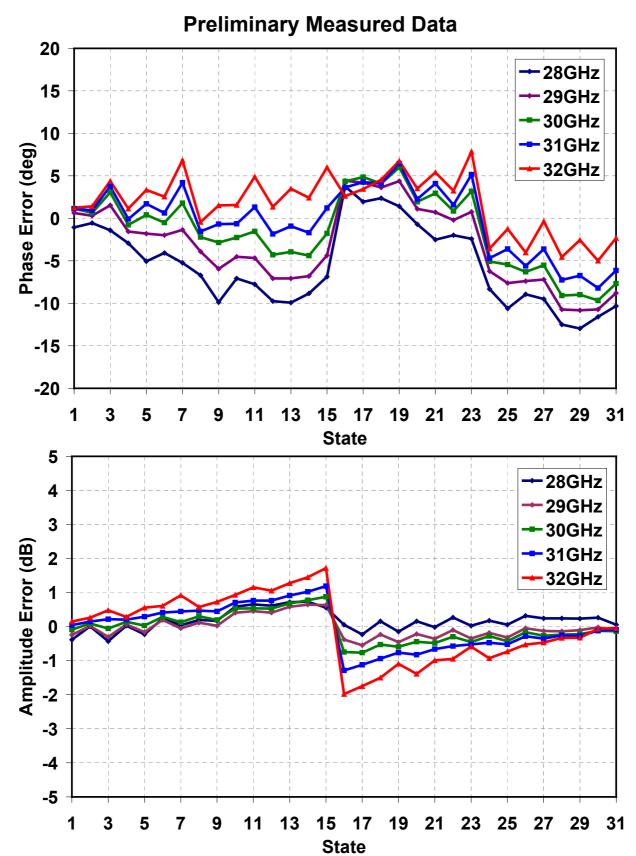
TGP2100-EPU

Preliminary Measured Data





TGP2100-EPU





TGP2100-EPU

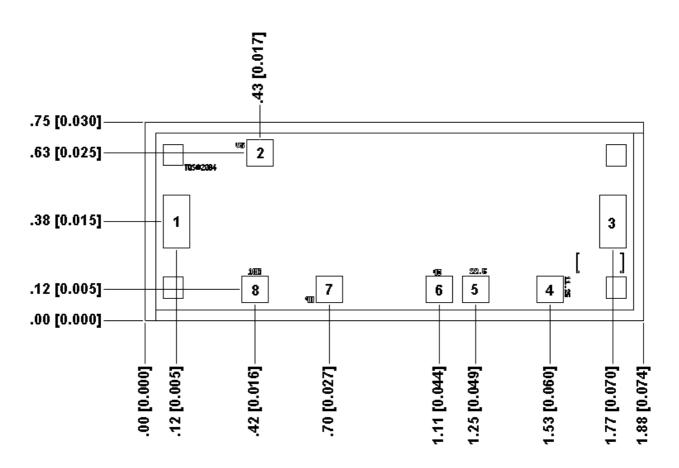
State Table

State	V-Supply	V-11.25	V-22.5	V-45	V-90	V-180	Phase Shift
0	+5V	0V	0V	0V	0V	0V	Reference
1	+5V	+5V	0V	0V	0V	0V	11.25°
2	+5V	0V	+5V	0V	0V	0V	22.5°
3	+5V	+5V	+5V	0V	0V	0V	33.75°
4	+5V	0V	0V	+5V	0V	0V	45°
5	+5V	+5V	0V	+5V	0V	0V	56.25°
6	+5V	0V	+5V	+5V	0V	0V	67.5°
7	+5V	+5V	+5V	+5V	0V	0V	78.75°
8	+5V	0V	0V	0V	+5V	0V	90°
9	+5V	+5V	0V	0V	+5V	0V	101.25°
10	+5V	0V	+5V	0V	+5V	0V	112.5°
11	+5V	+5V	+5V	0V	+5V	0V	123.75°
12	+5V	0V	0V	+5V	+5V	0V	135°
13	+5V	+5V	0V	+5V	+5V	0V	146.25°
14	+5V	0V	+5V	+5V	+5V	0V	157.5°
15	+5V	+5V	+5V	+5V	+5V	0V	168.75°
16	+5V	0V	0V	0V	0V	+5V	180°
17	+5V	+5V	0V	0V	0V	+5V	191.25°
18	+5V	0V	+5V	0V	0V	+5V	202.5°
19	+5V	+5V	+5V	0V	0V	+5V	213.75°
20	+5V	0V	0V	+5V	0V	+5V	225°
21	+5V	+5V	0V	+5V	0V	+5V	236.25°
22	+5V	0V	+5V	+5V	0V	+5V	247.5°
23	+5V	+5V	+5V	+5V	0V	+5V	258.75°
24	+5V	0V	0V	0V	+5V	+5V	270°
25	+5V	+5V	0V	0V	+5V	+5V	281.25°
26	+5V	0V	+5V	0V	+5V	+5V	292.5°
27	+5V	+5V	+5V	0V	+5V	+5V	303.75°
28	+5V	0V	0V	+5V	+5V	+5V	315°
29	+5V	+5V	0V	+5V	+5V	+5V	326.25°
30	+5V	0V	+5V	+5V	+5V	+5V	337.5°
31	+5V	+5V	+5V	+5V	+5V	+5V	348.75°



TGP2100-EPU

Mechanical Drawing



Units: millimeters [inches]

Thickness: 0.10 [0.004] (reference only)

Chip edge to bond pad dimensions are shown to center of bond pads.

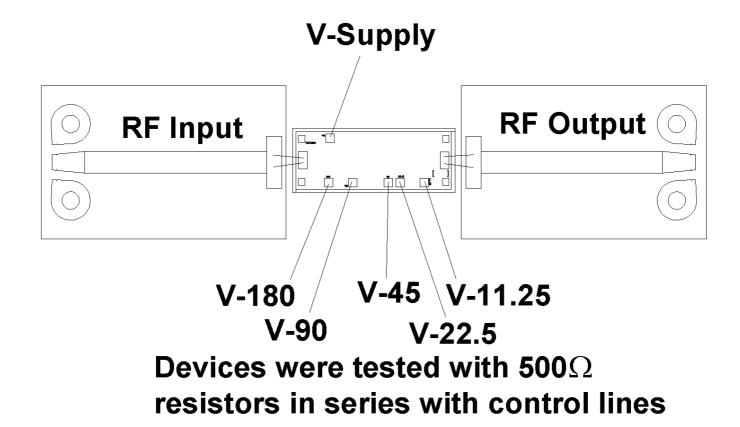
Chip size tolerance: ±0.05 [0.002]
RF ground through backside

Bond Pad #1	RF Input	0.10 x 0.20	[0.004 x 0.008]
Bond Pad #2	V-Supply (+5V)	0.10 x 0.10	[0.004 x 0.004]
Bond Pad #3	RF Output	0.10 x 0.20	[0.004 x 0.008]
Bond Pad #4	V-11.25 (ON V=+5V)	0.10 x 0.10	[0.004 x 0.004]
Bond Pad #5	V-22.5 (ON V=+5V)	0.10 x 0.10	[0.004 x 0.004]
Bond Pad #6	V-45 (ON V=+5V)	0.10 x 0.10	[0.004 x 0.004]
Bond Pad #7	V-90 (ON V=+5V)	0.10 x 0.10	[0.004 x 0.004]
Bond Pad #8	V-180 (ON V=+5V)	0.10 x 0.10	[0.004 x 0.004]



TGP2100-EPU

Chip Assembly & Bonding Diagram



GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.



TGP2100-EPU

Assembly Process Notes

Reflow process assembly notes:

- Use AuSn (80/20) solder with limited exposure to temperatures at or above 300°C. (30 seconds maximum)
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Maximum stage temperature is 200°C.

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